

# Electromagnetic embossing and forming of optical microstructures

I2FG

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# **Motivation**







# Technology





# **Experimental set up**





















# **Quality of embossed surface**



probe initial surface Sa = 1000 nmtool surface Sa = 20 nmprobe embossed surface Sa = 44 nm



s <sub>0</sub>	=	0.3	mm
d	=	0.9	mm
$E_C$	=	1.8	kJ

# probe

#### 50 µm

**Sequenced forming** 





microstructure can be inside or outside of the freeformed macrogeometry due to the application of the formed part

# **Cross structure – 1<sup>st</sup> step**





sheet







## **Cross structure – 2<sup>nd</sup> step**







- replication of microstructures
- replication of surface quality with near optical finish
- embossing thin micro metal sheets
- free forming of structured sheets
- complex optical geometries realizable
- shorter manufacturing times
- lower invest (tools)



### **Future work**

- 1<sup>st</sup> step • embossing of more complex micro structures
- embossing of optical diffractive structures
- controlling macro geometry and shape step **N**nd by adapted micro structures







# Contact



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# Thanks to ....

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